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DOI: 10.1016/j.eswa.2019.112826

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Document Version Peer reviewed version

Citation for published version (Harvard):

De la Torre Gutierrez, H & Pham, D 2019, 'A control chart pattern recognition system for feedback-control processes', *Expert Systems with Applications*, vol. 138, 112826. https://doi.org/10.1016/j.eswa.2019.112826

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Title: A control chart pattern recognition system for feedback-control processes

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Abstract

The automated diagnosis of control charts to detect faults is a problem studied by many researchers. In recent years, they have turned their attention to processes that do not fulfil the condition of having normally, identically and independently distributed (NIID) variables. With those processes, it is common to have one or more manipulatable variables that can affect the quality characteristic under investigation. The Engineering Process Control (EPC) approach is often used to minimise the variance around the target value of the monitored characteristic by adjusting the manipulatable variables. In this work, a control chart pattern recognition (CCPR) system was developed for processes adjusted by EPC (also known as SPC-EPC or feedback-control processes). This issue of simultaneous identification of simple control chart patterns for feedback-control processes had previously not been studied. A Machine Learning algorithm was proposed to train a pattern recognition system. All the possible combinations of factors of the CCPR system were studied to determine the combination yielding the highest recognition accuracy, namely, using raw data as input, generating patterns with significance level α =0.01, monitoring the output signal, and employing a Proportional Integrative Derivative (PID) controller and the Radial Basis Function (RBF) kernel. This combination yielded overall accuracies of 94.18% and 94.14% for the AR(1) and ARMA(1,1) models, respectively.

Keywords: Control chart pattern recognition, PID control, Support Vector Machine, SPC, EPC

Comment [HDITG1]: I hope this phrase is understood as "identify any of the seven simple patterns, not only by pairs or a subset of patterns as it was done by other authors.

Abbreviations

| ANOVA | Analysis of variance |
|----------------|---|
| AR(1) | First-order autoregressive |
| ARMA(1,1) | First-order autoregressive moving-average |
| BA | Bees Algorithm |
| BESSEL | Bessel kernel |
| CCPR | Control chart pattern recognition |
| CI | Confidence interval |
| СҮС | Cyclic pattern |
| Dt | Disturbance magnitude at time t |
| DS | Downward shift |
| DT | Downward trend |
| et | White noise at time t |
| EPC | Engineering process control |
| HDWT | Haar discrete wavelet transform |
| IMA (1,1) | First-order integrated moving-average |
| IRT | Input representation technique |
| k _D | Coefficient for the derivative part of the controller |
| k _I | Coefficient for the integral part of the controller |
| k _P | Coefficient for the proportional part of the controller |
| MMSE | Minimum mean square error |
| MSE | Mean square error |
| n | Sample size |
| N _t | Inherent noise at time t |
| NIID | Normally, identically and independently distributed |
| NN | Neural network |
| NORM | Normal pattern |

| PGS | Pattern generation scheme |
|---------------------------|--|
| PGS-1 | Conventional pattern generation scheme |
| PGS-2 | Pattern generation scheme with $\alpha = 0.01$ |
| PI | Proportional integral |
| PID | Proportional integral derivative |
| RBF | Radial basis function |
| $\mathbf{S}_{\mathbf{t}}$ | Scaled variable at time t |
| sin | Sine function |
| SPC | Statistical process control |
| SVM | Support Vector Machine |
| SYS | Systematic pattern |
| Т | Target value |
| t | Time |
| US | Upward shift |
| UT | Upward trend |
| X _t | Controller compensation at time t |
| Y _t | Output variable at time t |
| Zt | Observed quality characteristic before the controller compensation |
| α | Significance level |
| β | Abnormal pattern parameter |
| ϕ | Autoregressive coefficient |
| σ_{e} | Standard deviation of white noise |
| $\sigma_{\rm N}$ | Standard deviation of inherent noise |
| τ | Time when a break point occurs |
| θ | Moving-average coefficient |

1. Introduction

Statistical Process Control (SPC) is a collection of statistical techniques aimed at identifying assignable causes of variations in a process by monitoring the process and analysing the data obtained. If assignable causes are efficiently determined, two benefits can be achieved: reduction of the variance of the output variable and increase of the monitoring capability. One of the most efficient tools used by SPC is the control chart (CC). There are two main approaches to analysing and identifying assignable causes with CC. The first approach is to apply run rules or zone tests. However, there might be more than one assignable cause related to each rule or test, which creates uncertainty. The second approach involves the identification of patterns in the control chart. When the process is running under its intended conditions, the control chart displays a "Normal" (NORM) pattern (see Figure 1). On the other hand, if there are external disturbances (assignable causes), the control chart can exhibit one or more of the fourteen different types of abnormal patterns (Western Electric Company, 1956). Six of these patterns are considered basic patterns: Upward/Downward Trends (UT/DT), Upward/Downward Shifts (US/DS), Cycles (CYC) and Systematic (SYS). Figure 1 outlines these simple patterns. The remaining eight patterns are regarded as either particular cases or combinations of the basic patterns.

[Insert]Figure 1: Seven simple patterns in control charts

Reduction of the variance in the monitored variables is essential in modern manufacturing due to the need to increase quality and reduce scrap. In discrete part manufacturing, SPC has shown to be effective at addressing assignable causes. However, when the aim of monitoring is the reduction of the variance of the process, SPC has not always succeeded. On the other hand, in continuous processes, different process conditions are observed. The most common

control charts cannot be used to monitor a continuous process as the assumption of time independence of the monitored quality characteristics is not fulfilled in most continuous processes. For these processes, it is usual that the variance of the output variable (the quality characteristic of interest) is reduced by means of a compensation or regulation scheme acting on manipulatable variables. These process compensation or regulation schemes are known as Engineering Process Control (EPC), stochastic control, or feedback/feedforward control, depending on the nature of the adjustments (Montgomery, 2009). A good quality control system is one that efficiently identifies patterns due to assignable causes and keeps the variance of the process at the minimum level, always around the nominal value of the process. Quality control systems that simultaneously monitor manipulatable variables and compensate for their effects are known as SPC-EPC or synergistic control schemes.

EPC schemes assume that changes in the manipulatable variables will have repercussions on the output variable in accordance with a specific dynamic model that links these variables. If this dynamic model is correct, the variance of the output variable is reduced. However, when certain types of external disturbances or assignable causes occur that are outside the framework of this dynamic model, then the compensation rules will not completely account for them. As a result, variability will be increased. By applying SPC in a specific way, these assignable causes can be detected and the combined SPC-EPC procedure will be more effective than EPC alone (Montgomery, 2009). As the identification of the aforementioned seven simple patterns in SPC-EPC schemes has not been fully studied, it was necessary to develop a control chart pattern recognition (CCPR) system for these process types.

CCPR systems for SPC-EPC schemes must take into account how the seven simple patterns are affected by the control scheme implemented by EPC. The main aim of this work is to develop CCPR systems for processes where the simple patterns are affected by a control scheme, as well as determining which variable - the output variable or the control compensations - is suitable for efficient identification of assignable causes from observed control chart patterns. Two different time series were used to model the inherent disturbance, the first-order autoregressive (AR(1)) and first-order autoregressive moving average (ARMA(1,1)) models, the ARMA(1,1) never studied before when a feedback control scheme is implemented. The simultaneous identification of the seven simple control chart patterns has not previously studied in feedback-control processes as highlighted ahead in the Literature review.

Two of the most common and effective controllers have been implemented and compared, namely, the Proportional Integrative Derivative (PID) and the Minimum Mean Squared Error (MMSE) controllers. As a consequence of applying controllers, two signals are produced: the output of the controller and the process output after the controller action. As aforementioned, determining which signal to monitor in order accurately to recognise patterns is another aim of this work. This comparative study of controllers when developing recognition systems is another contribution of this paper.

CCPR for feedback-control processes has not been much studied and the combination of factors (pattern generation scheme (PGS), input representation technique (IRT) and kernel of the Machine Learning algorithm) that yields the highest recognition accuracies is not known. Thus, the best combination of these factors is determined.

The rest of this paper is organised as follows. Section 2 reviews some of the publications most pertinent to this work. Section 3 presents the proposed CCPR system for feedback-control processes. The results obtained are discussed in Section 4. Finally, Section 5 concludes the paper and suggests areas for further investigation.

2. Literature review

The design of quality systems where SPC is integrated with EPC techniques has been an issue studied by several researchers during the last two decades.

This section reviews the most relevant publications related to SPC-EPC monitoring schemes and CCPR for normally, identically and independently distributed (NIID), autocorrelated and feedback-control processes.

2.1. SPC-EPC schemes

In SPC-EPC schemes, monitoring is typically conducted on the output of a controlled process (Del Castillo, 2006), but which signal to monitor in SPC-EPC control systems is still an unresolved issue. Jiang & Tsui (2002) demonstrated that monitoring either the output or the control action can be more efficient depending on the autocorrelated process dynamics. Other authors such as Box & Kramer (1992) and Capilla, Ferrer, Romero, & Hualda (1999) suggested that monitoring controller actions may improve the chances of early detection of shifts in the mean.

Kandananond (2010) quantified the effect of factors such as types of controllers, control charts and monitored signals on integrated SPC-EPC systems for non-stationary inherent disturbances when the Mean Squared Error (MSE) and average run length are measured as responses. Wang & Tsung (2007) proposed the use of the T^2 control chart for detecting dynamic patterns in mean shifts of Proportional-Integral (PI) controlled and MMSE controlled processes for inherent noise modelled by an ARMA(1,1) time series. For a broader discussion and review of the integration of SPC and EPC, see Jiang & Farr (2007).

2.2. CCPR for NIID processes

Designing CCPR systems that deal effectively with NIID inherent noise has recently been the most commonly studied problem (Hachicha & Ghorbel, 2012).

Xanthopoulos & Razzaghi (2014) proposed the use of weighted Support Vector Machines (SVM) for CCPR. Ranaee, Ebrahimzadeh, & Ghaderi (2010) introduced a CCPR system using a SVM as the recognition system and Particle Swarm Optimisation to improve the overall performance of the SVM by finding the best set of free parameters. Zhao et al. (2017) utilised Genetic Algorithms for searching the best set of free parameters in an improved-SVM-based pattern recognition system.

Pham & Wani (1997) proposed a set of shape features to be extracted directly from the control chart data and to be used as inputs for CCPR systems, increasing the pattern recognition accuracies and recognition stability. Based on these features, Gauri & Chakraborty (2006, 2009) suggested another set of shape features that not only increased pattern recognition accuracies and recognition stability but also were independent of the scale of the control chart data. Zaman & Hassan (2018) developed a two-staged recognition system, where the features are extracted and selected in the first stage, and in the final stage, the patterns are recognised using an adaptive neuro-fuzzy inference system (ANFIS) along with fuzzy c-mean (FCM).

Guh & Tannock (1999) developed a sequential pattern analysis scheme with four networks divided into two sequences in order to identify more detailed information about abnormal patterns. Using a sequence of networks to obtain more detailed information about the pattern was also studied by Guh (2003, 2005); Jiang, Liu, & Zeng (2009) and Shaban & Shalaby (2012). Authors such as Du, Huang, & Lv (2013); Lu, Shao, & Li (2011) and Xie et al.

(2013) have focused on the application of signal analysis techniques to pre-process the control chart data in order to enhance the performance of the CCPR system

2.3. CCPR for autocorrelated processes

(Noorossana, Farrokhi, & Saghaei, 2003) developed a multi-layer neural network-based CCPR system to detect three types of abnormal patterns referred to as level shift, additive outlier and innovation outlier. The inherent disturbance was modelled by an AR(1) model. Bo, Beibei, Yuwei, & Shengran (2018) designed a recognition system based on Random Forest and Classification and Regression Trees, where the inherent disturbance is also modelled by a AR(1).

Guh (2008) was the first author formally to study the identification of simple patterns in processes of which observations are not independent, using the AR(1) model to describe the inherent noise. He developed an on-line CCPR system for each of the nineteen autocorrelation levels studied. The designed on-line CCPR system neglected the biasing effect of the abnormal pattern over the estimated common-cause parameters (Boyles, 2000). Guh's study showed encouraging results, introducing a new direction in CCPR research.

Other authors (Lin, Guh, & Shiue, 2011; Yang & Zhou, 2015) developed on-line CCPR systems also neglecting how the correlation coefficient is biased when abnormal patterns occur, thus training one CCPR system for each of the studied autocorrelation levels.

Cheng & Cheng (2008) used a multi-resolution analysis approach based on the Haar Discrete Wavelet Transform (HDWT) to denoise, decorrelate and extract features from AR(1) processes. They studied five pattern types and employed a multi-layer neural network as recognition system. The recognition accuracies of the proposed CCPR system were compared with those obtained using raw data as input. The best combination of coefficients of the HDWT, approximation and detail, was determined by trial and error, causing long processing times and uncertainty. The proposed feature extraction technique increased the accuracy compared to those achieved using raw data as input. Wu & Yu (2010) developed a neural-network-based system for recognising both mean and variance shifts in AR(1) processes, providing additional useful information about process changes.

2.4. CCPR for feedback-control processes

The first authors to discuss the issue of pattern recognition and categorisation for feedbackcontrol processes were Shao & Chiu (1999). A neural network (NN) was used as pattern recognition system. A first-order integrated moving-average (IMA(1,1)) model was adopted to model the inherent noise and a PI controller, to adjust the process. The NN was trained to identify step and linear disturbances and their magnitudes and achieved good recognition accuracies.

Lu, Wu, Keng, & Chiu (2008) developed a neural-network-based model with independent component analysis to recognise shifts in the correlated process parameters. They only considered two pattern types, step and linear changes, and assumed that the process can be modelled by an IMA(1,1) time series. They used a PI controller to make adjustments to the process.

The issue of detecting the start time of some abnormal patterns was addressed by Shao, Lu, & Chiu (2011). The inherent disturbance was modelled with an AR(1) time series and a MMSE controller was employed to tune the process. SVM and NN were used to detect the start time of only step-changes with different magnitudes.

Shao (2014) trained three SVMs to recognise pattern types in pairs, i.e., he studied three pattern types, having three possible pairwise combinations and training one SVM for each pair. He also assumed that the inherent noise could be modelled by an AR(1) time series with

a given autocorrelation level (ϕ =0.9) and the process could be adjusted by a MMSE controller. As result, the proposed CCPR systems proposed by the author were able only to recognise patterns that showed that autocorrelation level and only distinguishing between patterns by pair.

The above review has revealed the need to develop CCPR systems for feedback-control processes robust to autocorrelation levels and able to identify the seven simple patterns simultaneously. It was noted that other time series models such as ARMA(1,1) must be considered to model the inherent noise before the controller action. Comparison between the two most efficient EPC controllers, MMSE and PID, is also required.

3. Proposed CCPR for feedback-control processes

3.1. Generation of the feedback-control processes

The proposed scheme for recognising patterns in feedback-control processes comprises three steps:

- i. Initial generation of in-control processes and estimation of the controller parameters. An autocorrelated process, N_t, is generated according to one of the two time series models employed in this work (see Appendix). Using N_t, the parameters of the following two controllers are estimated:
 - Minimum-Mean-Squared-Error (MMSE) controller (Jiang & Tsui, 2002):

$$X_{t} = \phi X_{t-1} + (\theta - \phi)(N_{t} - T)$$
(1)

The parameters ϕ and θ are estimated by fitting an ARMA(1,1) or AR(1) model to N_t. In this research, the target value, T, was set to zero without loss of generality.

Proportional Integral Derivative (PID) (Montgomery, 2009):

$$X_{t} = -k_{P}N_{t} - k_{I}\sum_{i=1}^{t}N_{i} - k_{D}(N_{t} - N_{t-1})$$
(2)

The parameters k_P , k_I , k_D are estimated by minimising the MSE of the output variable, N_t, constrained to the following stability region for stationary processes (Box, Jenkins, & Reinsel, 1994; Tsung & Shi, 1999):

$$\begin{cases} k_{I} \ge 0 \\ k_{P} + \frac{k_{I}}{2} + 2k_{D} < 1 \\ -1 < k_{D} < 1 \\ -k_{D}(1 + k_{P} + k_{I}) - k_{P} < 1 \end{cases}$$
(3)

- ii. Using the autocorrelated data, N_t, generated in (i), two methods were followed to produce patterns: the method adopted in most of the work on CCPR (denoted as PGS-1) and the scheme proposed by De la Torre Gutiérrez & Pham (2018) based on testing the statistical significance of the pattern parameters (denoted as PGS-2). In the first scheme, patterns are generated directly from equations (A2) - (A6) in the appendix and no further treatment is made to the data. In the second scheme, by fitting a dynamic regression model to the control chart data, the statistical significance of the pattern parameters is tested. The significance level chosen in this work was $\alpha = 0.01$. This level had been tested in previous work (De La Torre Gutierrez & Pham, 2016, 2018) to yield the best recognition accuracy.
- iii. Once the patterns have been generated and the parameters of the PID and MMSE controllers have been estimated, the controller is applied and two different variables are obtained from the original, the feedback-control output, Y_t, and the controller compensations, X_t. Y_t can be obtained from:

$$Y_t = Z_t + X_{t-1} \tag{4}$$

where Z_t represents the disturbance as described in the Appendix.

Determining which of these two signals, Y_t or X_t , to monitor and analyse in order to achieve the highest pattern recognition accuracy is a key point in this work.

3.2. Input factors of the CCPR system

In addition to the pattern generation methods described in the previous subsection, the CCPR scheme also involves applying an IRT and a recognition system.

- The two IRTs tested in this work were:
 - Normalised raw data: The length of the input vector is preserved and the data are scaled to enable the CCPR system to recognise patterns in processes with any process mean and standard deviation (Zorriassatine & Tannock, 1998). The following expression was used for normalisation:

$$S_t = \frac{O_t - \bar{O}}{\hat{\sigma}_o} \tag{5}$$

where \bar{O} and $\hat{\sigma}_o$ represent the mean and standard deviation of the output variable, X_t or Y_t, respectively.

- Shape features: To reduce the dimension of the input vector, the shape features initially proposed by Pham & Wani (1997) and then improved by Gauri (2010) for NIID observations are extracted. These features are independent of the data scale, increase pattern recognition accuracies and reduce training time.
- Machine Learning kernels: SVM was used as the pattern recognition algorithm in this work. SVM is a relatively recent Machine Learning algorithm. It has many advantages compared to other existing methods: generalisation capacity, ease of use and solution uniqueness (De Tejada & Martinez-Echevarria, 2007). SVMs can also deal with nonlinear formulations, provide a trade-off between dimensionality (space complexity) and accuracy and produce good results in pattern recognition

applications. Three SVM kernels for nonlinear classification were tested, namely, Radial Basis Function (RBF), Laplace (LAPLA) and Bessel.

Figure 2 depicts the proposed scheme for CCPR of feedback-control processes for each inherent noise model.

[Insert]Figure 2: Proposed scheme for CCPR of feedback-control processes

3.3. Training of the pattern recognition system

Two sets of 5600 patterns, 800 of each type, were generated; one of the sets was produced using the methodology proposed by De la Torre Gutiérrez & Pham (2018), and the other following the PGS adopted in most of the CCPR literature (Pham, Otri, Ghanbarzadeh, & Koc, 2006; Pham & Oztemel, 1996). Each synthesised pattern consisted of a random sequence of length n=60, sampled at time $t_1, t_2,...,t_{60}$.

The Bees Algorithm (BA) proposed by Pham et al. (2006) was chosen to determine the best set of SVM parameters that minimise the misclassification rate during training. The misclassification rate under five-fold cross validation was selected as the loss function to be minimised. The BA was chosen for its proven ability to find globally optimal solutions in diverse complex optimisation problems, using both local and global search techniques (Pham, Castellani, & Chen, 2015). Table 1 shows the BA parameter values used. For further information regarding this algorithm and its parameters, see Pham et al. (2006) and Yuce, Packianather, Mastrocinque, Pham, & Lambiase (2013).

Table 1: Parameters of the BA used during SVM training

| Parameter | Symbol | Value |
|-------------------------|--------|-------|
| Initial population | nb | 20 |
| Number of "best" sites | т | 3 |
| Number of "elite" sites | е | 2 |

| Patch size for Cost parameter <i>C</i> | ngh-c | 0.5 |
|--|-------|------|
| Patch size for Kernel parameters | ngh-k | 0.02 |
| Number of bees for the elite sites | ne | 3 |
| Number of bees for the remaining "best" points | nb | 2 |

4. Results

For each inherent noise model, 200 test sets of 700 patterns each were generated, 100 sets using PGS-2 and the remaining using PGS-1. For simplicity, the analysis of accuracies has been divided into two parts; in the first part, the best combination of input factors is determined. In the second part, the performance for that combination is studied and disaggregated by controller type and pattern type.

4.1. Analysis of input factors

Figure 3 shows the mean accuracies and the 95% confidence intervals (CIs) found for the AR(1) process for the five studied factors, disaggregated by pattern type. Figure 4 gives the recognition accuracies achieved when the inherent noise was ARMA(1,1) distributed and the 95% CIs for these accuracies for the five factors.

To determine which of the aforementioned five factors affects the recognition accuracy, a 2^4 x3 Analysis of Variance (ANOVA) with up to quintuple interactions was utilised.

Table 2 shows the p-values obtained from the aforementioned ANOVA for the AR(1) and ARMA(1,1) models; the triple, quadruple and quintuple interactions have been omitted.

| Factor | AR (1) | ARMA(1,1) |
|------------|---------------|-----------|
| PGS | ≈0 | ≈0 |
| IRT | ≈0 | ≈0 |
| SIGNAL | ≈0 | ≈0 |
| KERNEL | ≈0 | ≈0 |
| CONTROLLER | ≈0 | ≈0 |

Table 2: p-values obtained from ANOVA for the five input factors

| PGS*CONTROLLER | ≈0 | ≈0 |
|-------------------|--------|---------------------------------------|
| | | · · · · · · · · · · · · · · · · · · · |
| IRT*CONTROLLER | ≈0 | ≈0 |
| SIGNAL*CONTROLLER | ≈0 | ≈0 |
| KERNEL*CONTROLLER | 0.4893 | ≈0 |
| PGS*IRT | 0.1723 | ≈0 |
| PGS*SIGNAL | ≈0 | ≈0 |
| PGS*KERNEL | 0.3730 | 0.2849 |
| IRT*SIGNAL | ≈0 | ≈0 |
| IRT*KERNEL | ≈0 | ≈0 |
| SIGNAL*KERNEL | 0.3614 | 0.0008 |

[Insert] Figure 3: Results for the five factors of the AR(1) model

[Insert] Figure 4: Results of the five factors for the ARMA(1,1) process

4.2. Analysis of the best factor arrangement

For the analysis of the best arrangement, the controller type was taken as the fixed factor and its interaction with the inherent noise model was studied. The performance of each modelcontroller type has been analysed by a post-hoc Tukey test. Table 3 presents the results obtained.

Table 3: Best factor arrangements for AR(1) and ARMA(1,1) models

| Model-Controller | Best arrangement | | | |
|------------------|------------------|---------------------|-------------|----------------|
| Model-Controller | PGS | IRT | Kernel | Signal |
| AR-PID | PGS-2 | Raw data | RBF | Y _t |
| AR-MMSE | PGS-2 | Raw data / Features | RBF | Y _t |
| ARMA-PID | PGS-2 | Raw data | RBF | Y _t |
| ARMA-MMSE | PGS-2 | Raw data / Features | RBF / LAPLA | Yt |

Table 4 shows the accuracies for each optimal arrangement, disaggregated by controller type and pattern. It can be observed that the accuracies for Normal patterns when a PID controller was applied were the lowest. As for the MMSE controller, the worst accuracies were observed for CYC patterns.

| | | AR | A | RMA |
|-------|----------------|----------|----------------|----------|
| | PID (%) | MMSE (%) | PID (%) | MMSE (%) |
| TOTAL | 94.18 | 81.53 | 94.14 | 76.93 |
| NORM | 88.13 | 82.93 | 88.95 | 81.32 |
| UT | 93.00 | 77.66 | 92.70 | 70.66 |
| DT | 95.99 | 81.58 | 96.48 | 73.24 |
| US | 94.12 | 78.21 | 93.58 | 82.79 |
| DS | 98.60 | 90.64 | 98.04 | 87.66 |
| CYC | 92.63 | 77.41 | 93.10 | 70.12 |
| SYS | 96.82 | 82.25 | 96.15 | 72.72 |

Table 4: Accuracies using the best arrangements of factors

To measure the impact of the controllers, the recognition accuracies achieved in this research were compared with those achieved in De la Torre Gutiérrez & Pham (2018) where no controllers were utilised. The results of the comparison are shown in Table 5.

| | AR | | | ARMA | | |
|-------|-------|---------------|------------|-------|---------------|------------|
| | PID | No controller | Difference | PID | No controller | Difference |
| TOTAL | 94.18 | 90.03 | 4.15 | 94.14 | 89.28 | 4.86 |
| NORM | 88.13 | 83.92 | 4.21 | 88.95 | 81.04 | 7.91 |
| UT | 93.00 | 91.08 | 1.92 | 92.70 | 89.81 | 2.90 |
| DT | 95.99 | 93.60 | 2.39 | 96.48 | 93.30 | 3.19 |
| US | 94.12 | 79.70 | 14.42 | 93.58 | 83.04 | 10.54 |
| DS | 98.60 | 96.64 | 1.96 | 98.04 | 95.63 | 2.41 |
| CYC | 92.63 | 90.97 | 1.66 | 93.10 | 89.47 | 3.63 |
| SYS | 96.82 | 94.28 | 2.54 | 96.15 | 92.71 | 3.44 |

Table 5: Accuracies with and without controller application (%)

As shown in Table 5, the overall accuracy increased by 4.15% and 4.86% for the AR and ARMA processes, respectively. Regarding the pattern type, US patterns showed the highest rise in recognition accuracy, by 14.42% and 10.54% for the AR and ARMA processes, respectively. This could have been caused by the amplitude effect of the controller on the magnitude of abnormal patterns.

4.3. Real data application

To demonstrate the ability of the proposed CCPR system to handle real data, 60 measurements of the thickness of a very thin metallic film in the early stages of the development of an electronic device taken from Box, Luceño, & Paniagua-Quiñones (2009) were utilised (corresponding to observations 11 to 70), and the SPC-EPC approach was followed to adjust and monitor this quality characteristic (see Figure 5). Box et al. (2009) highlighted the existence of an assignable cause that abruptly increased the metallic film thickness after 30 observations.

[Insert] Figure 5: Thickness of metallic film in the early stages of the development of an electronic device

The CCPR trained with the best arrangement of input factors for the two signals (X_t and Y_t) were used, and NORM and US patterns were identified for Y_t and X_t , respectively (see Figure 6). As mentioned in Box et al. (2009), in the process before the adjustment, a US pattern can be observed. Therefore, this pattern is expected to be recognised in one of the two signals, in this case, X_t .

In order further to categorise the pattern recognised by the aforementioned CCPR system, the methodology proposed for autocorrelated inherent noise was applied, i.e., two NLM-ARMA proposed for autocorrelated patterns were fitted to the original data. The p-value corresponding to the F-test for nested models was 0.0020; therefore, the full model better fitted the data. The most likely breakpoint was detected at $\tau = 30$. Table 6 shows all the values regarding the full model fitted. It can be observed that the parameter related to the Shift pattern is statistically significant and greater than zero. Thus, like the CCPR, the NLM-ARMA classifies the pattern as a US pattern.

[Insert] Figure 6: Output and controller signals obtained from the SPC-EPC process

| Parameter | Estimate | Std. Error | t value | p-value |
|-------------------------|----------|------------|---------|---------|
| φ | 0.306 | 0.1066 | 2.8701 | 0.0041 |
| Intercept | 80.5090 | 2.9488 | 27.3023 | 0.0000 |
| Slope (Trend) | 0.1784 | 0.0986 | 1.8093 | 0.0740 |
| Shift magnitude (Shift) | 18.4251 | 4.0195 | 4.5839 | 0.0000 |
| Amplitude (Cyclic) | 0.7434 | 1.4738 | 0.5044 | 0.6140 |
| Frequency (Cyclic) | 3.2311 | 1.0233 | 3.1575 | 0.0016 |
| Departure (Systematic) | 0.4504 | 1.2484 | 0.3608 | 0.7183 |

Table 6: ANOVA of the NLM-ARMA model fitted to the thickness measurements for a metallic film

5. Conclusion

An important aspect to pay attention to when developing CCPR models is that they must be general, i.e., able to identify a wide variety of patterns. The generation of training patterns to ensure generality of the CCPR model and to create benchmarks for comparing recognition accuracies is an issue studied by De la Torre Gutiérrez & Pham (2016, 2018) who developed PGSs with that specific aim. The PGS proposed for autocorrelated patterns was the one adopted in this work. The control chart patterns, Z_t, were synthesised using two different PGSs, PGS-1 and PGS-2. PGS-2 (De la Torre Gutiérrez & Pham, 2018) ensured that correct decision boundaries were drawn and the patterns were appropriately categorised before the action of the controller. Therefore, the models developed using PGS-2 represent general CCPR models and can be employed in real-world applications.

SPC-EPC is a quality improvement technique that has shown good performance in a variety of production systems. As stated by Western Electric Company (1956), when a process is affected by assignable causes, SPC control charts exhibit patterns that can reveal those causes. However, those patterns have not been fully studied when feedback controllers are

used in EPC to reduce the variability of the output. This paper has described the design of CCPR for feedback-control processes. This task involves several factors such as IRT and signals to be monitored, determining the best arrangement of these factors being the focus of this paper. Another factor that can be set by production personnel and that was also studied here is the controller type, PID and MMSE being the two most commonly adopted.

In the case of the AR(1) model, employing a PID controller and monitoring the output variable using the raw data as IRT was the arrangement that yielded the highest pattern recognition accuracies. In the case of the MMSE controller, the raw output data used as IRT also gave the best accuracies. The RBF, LAPLA and Bessel kernels showed similar accuracies for both controllers.

When the ARMA(1,1) model was employed, using raw data also produced the highest pattern recognition accuracy for both controllers. As in the case of the AR(1) model, the RBF, LAPLA and Bessel kernels also showed similar accuracies for both controllers.

As noted the previous section, to achieve the highest recognition accuracies, it is recommended to monitor the raw data of the signal Y_t

It is worth noting how different the recognition accuracies were between the controllers. For the AR(1) model, the overall difference was 12.60% and for the ARMA(1,1) model, it was 17.21%.

The proposed recognition systems only deal with two stationary time series models (AR and ARMA), so the future work will be focused on developing PGS and CCPR systems for nonstationary processes (SARIMA and ARIMA models). Furthermore, another limitation of the proposed schemes is that the recognition accuracies are far to be satisfactory in nowadays industries, so increasing the recognition accuracies is also necessary. As noted in the Results section, the recognition accuracies achieved when the MMSE controller is applied are low, around 80%, so future work could be focused on how to increase the accuracy, this can be achieved by either applying signal processing techniques or using Deep Learning algorithms as pattern recognisers.

Future research will also focus on studying the identification of patterns in multivariate control charts, not only in the presence of autocorrelation but also in feedback-control processes and where assignable causes can be masked. Another research topic to study is the application of the T^2 control chart to simultaneously monitor the output and controller performance in feedback-control processes.

6. Appendix

Two time series models were used to model the inherent noise of the monitored process, ARMA(1,1) and AR(1).

$$N_t = \phi N_{t-1} - \theta e_{t-1} + e_t \tag{A1}$$

where if θ =0, an AR(1) process is obtained. et represents white noise which is normally, independently and identically distributed, with mean equal to zero and standard deviation equal to one. For further information about generating stationary processes starting from white noise et, see Box, Luceño, & Paniagua-Quiñones (2011).

The seven simple patterns, represented by D_t , were generated using the following expressions:

✤ Normal:

$$D_t = T \tag{A2}$$

Upward / Downward Trends:

$$D_t = \pm \beta_1 t + T \tag{A3}$$

Upward / Downward Shifts:

$$D_t = \pm \beta_2 d + T \tag{A4}$$

✤ Cyclic:

$$D_t = \beta_3 \sin\left(\frac{2\pi t}{\beta_4}\right) + T \tag{A5}$$

✤ Systematic:

$$D_t = \beta_5 (-1)^t + T \tag{A6}$$

The meaning of the parameters and ranges used in this research are shown in Table A1:

| Pattern | Parameter | Range | Meaning |
|----------------------------------|----------------|--|---|
| Target value | Т | Set to 0 | Nominal value of the quality characteristic under study |
| Upward trend | β ₁ | From $0.01\sigma_N$ to $0.30\sigma_N$ | Slope |
| Downward trend | β_1 | From -0.30 σ_N to -0.01 σ_N | Slope |
| Upward shift / Downward shift | d | 0 or 1, 0 when $t < \tau$ and 1 when $t \ge \tau$ τ , from 16 to n-15 | au is the time when the mean shift occurs. |
| Upward shift | β ₂ | From $0.01\sigma_N$ to $3.0\sigma_N$ | Mean shift magnitude |
| Downward shift | β_2 | From -3.0 σ_N to -0.01 σ_N | Mean shift magnitude |
| Cyclic | β ₃ | From $0.01\sigma_N$ to $3.0\sigma_N$ | Cycle amplitude |
| Cyclic | β4 | From 3 to 16 | Frequency |
| Systematic | β ₅ | From $0.01\sigma_N$ to $3.0\sigma_N$ | Systematic departure |

Table A1: Parameter definitions

In Table A1 σ_N represents the standard deviation of the ARMA model used for modelling the inherent noise, calculated the following expression:

$$\sigma_N = \sqrt{\frac{1+\theta^2 - 2\phi\theta}{1-\phi^2}}\sigma_e \tag{A7}$$

The magnitudes of the patterns were determined to remain in $6\sigma_N$ control in the inspection window. The window length, n, was set to 60. The frequencies of the CYC patterns were such that the patterns had at least four cycles in the inspection window.

The change points of the Shift patterns were randomly chosen between τ =16 and τ = *n*-15. This was due to the number of parameters to be estimated and the degrees of freedom available during the PGS application.

Let Z_t be the quality characteristic under study without the effect of the controller, defined as follows:

$$Z_t = N_t + D_t \tag{A8}$$

Patterns, represented by Z_t , are autocorrelated control chart patterns like those generated and studied in De la Torre Gutiérrez & Pham (2018) (and denoted as Y_t therein).

7. Acknowledgments

The first author wishes to acknowledge the Mexican National Council for Science and Technology, CONACYT, for enabling him to pursue graduate studies at the University of Birmingham – United Kingdom under grant No. 381672. The authors also acknowledge the high performance computing support given by the Birmingham Environment for Academic Research (BEAR).

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